

Schematic view of BL28B2 optics hutch 2

- Water filter

The filter has variable length from 5 mm to 50 mm.

- Fast shutter

Two tantalum plates of 5 mm thick are operated with rotary solenoid.

It has minimum exposure time with 1 msec and resolution of 1 msec.

The aperture size is 5 mm × 5 mm.

- Additional diffractometer

Vertical-axis ω - 2θ diffractometer is equipped for a single-bounce crystal monochromator.

- Main diffractometer

Vertical-axis ω - 2θ diffractometer is equipped for samples.

The stage for detectors is set on 2θ arm.

Detector translation stage on the χ goniometer.

X-Y-Z-R_x-R_y goniometer head on the ω -axis.

- Intensity measuring devices

Ionization chamber for I_0 monitoring

NaI scintillation detectors

Ge solid state detector (SSD)

Multi-channel Analyzer with ADC&HV module for SSD
NIM-based bins, HV's, amplifiers, single-channel analyzers, voltage-to-frequency converters (VFC) for ionization chambers.

Current amplifiers and pico-ammmeters

Digital multi-meter

XT-chart recorder

- Image recording devices

Imaging plate, Beam monitor with CCD

X-ray TV

Cassettes for X-ray films and photographic plates

Nuclear emulsion plates (Ilford L4) and high-resolution

X-ray films (minimum stock for emergency)

- Sample environment

Infrared heater (up to 1770 K)

Cryostat (3.8 K)

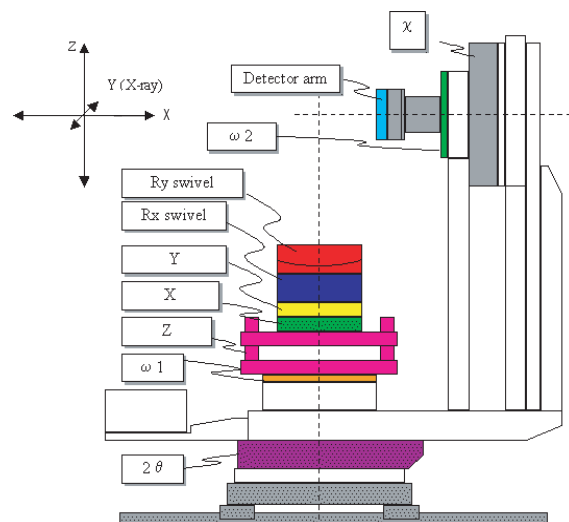
- Accessories

Optical microscope with CCD camera connected to a PC based data analysis system

Darkroom facility for photographic processing

Constant low temperature (5°C) cabinet for keeping films, plates and photo-chemicals

name	axis	resolution	Range
ω 1	Z	1/1000 deg.	360 deg.
2θ	Z	1/1000 deg.	360 deg.
X	X	2/1000 mm	± 20 mm
Y	Y	2/1000 mm	± 20 mm
R _x swivel	X	1/1000 deg.	± 7.5 deg.
R _y swivel	Y	1/1000 deg.	± 7.5 deg.
Z	Z	2/1000 mm	± 50 mm
χ	horizontal	1/1000 deg.	360 deg.
detector arm	-	2/1000 mm	± 200 mm
ω 2	horizontal	1/1000 deg.	360 deg.



Optics hutch 3

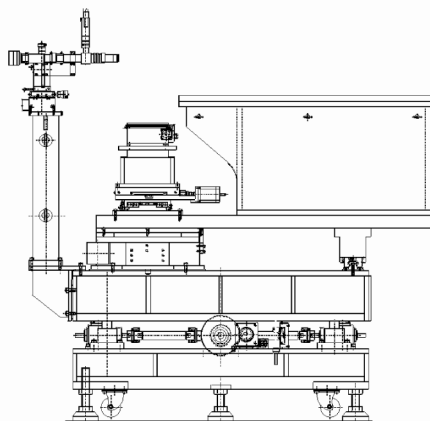
OH 3 is designed for a structural study of expanded fluid metals over the critical point at high pressure and high temperature. The main facility is a high pressure vessel and equipped with a horizontal energy-dispersive X-ray

diffractometer. The vessel has Be windows for the incident and scattered X-ray beam ($2\theta = 4, 7, 11.5, 15, 20, 25, 33^\circ$). High-purity He gas is used for a pressure medium, and a fluid sample contained in a single crystal sapphire cell is surrounded by compressed He gas in the vessel. The pressure is measured by a Heise gauge at an accuracy of ± 0.3 MPa. The system is suitable for high pressure and high temperature X-ray diffraction measurement up to 200 MPa and 2,000°C and has been applied to investigate structural changes with volume expansion for various fluid materials.

Horizontal energy-dispersive X-ray diffractometer

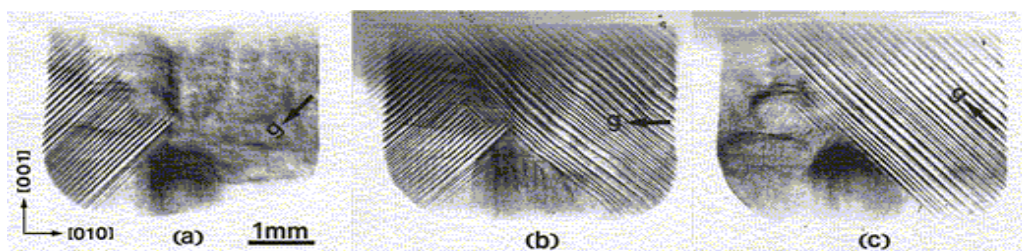
The diffractometer consists of a 2θ goniometer for a detector, translation XYZ stages for sample alignment and a vertical-axis θ goniometer. The whole system is set on a height adjustable surface plate.

name	resolution	range
Sample alignment		
θ goniometer	4/1000 deg.	360 deg.
Z stage	2/10 μm	± 10 mm
XY stage	2 μm	± 50 mm
Detector alignment		
2θ goniometer	4/100000 deg.	-40 ~ 120 deg.
Surface plate		
Z stage	0.186 μm	-5 ~ 35 mm



Side view of the diffractometer in OH 3

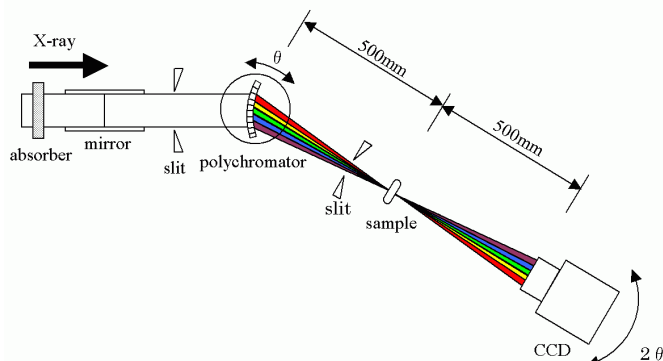
- High pressure gas vessel (helium 200 MPa, 2,000 °C)
- Pure Ge solid-state detector
- Ionization chamber



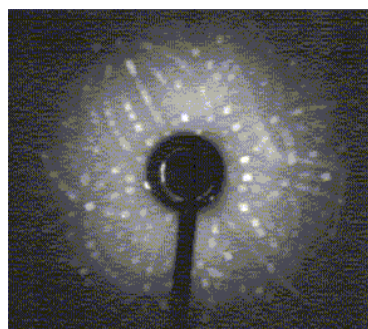
Low temperature Laue topographs of SrTiO₃ at 6 K

DXAFS

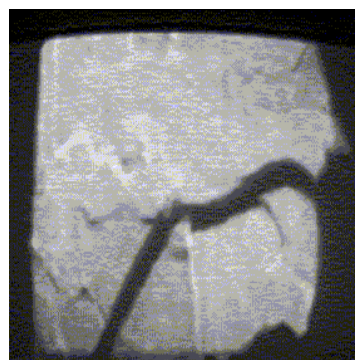
The main equipment of the DXAFS system consists of a polychromator with a bent silicon crystal, a higher-harmonic-rejecting mirror, a CCD coupled with a scintillating screen and a lens system.



Typical results in OH 2

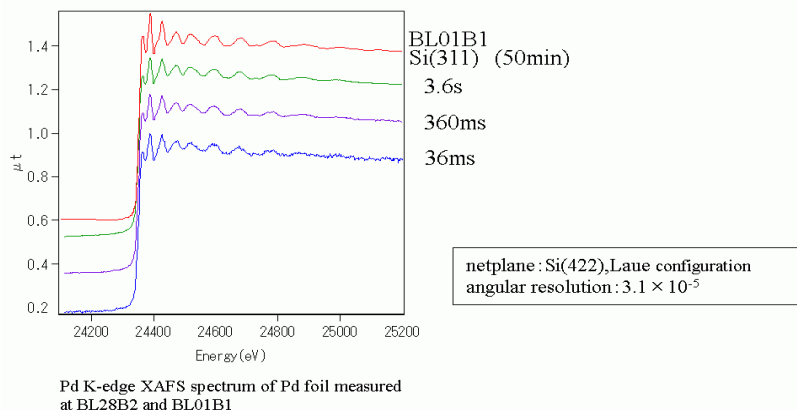


Laue pattern of tetragonal lysozyme crystal

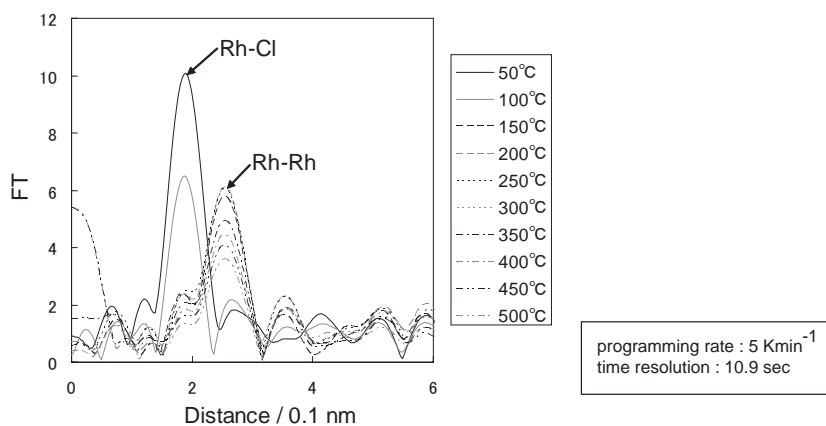


High temperature Bragg topograph of silicon steel at 965 K

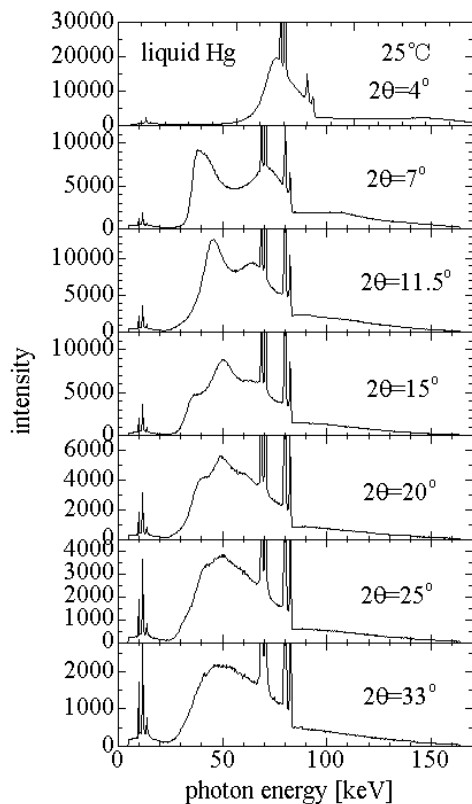
Typical results in OH 3



Measurement of reduction process of Rh/SiO₂ catalyst



The sample was treated at different temperatures in H₂ gas.



Spectrum of liquid Hg in standard condition

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